

APPENDIX IV: COPY OF PENDING CLAIMS,
AS AMENDED HEREIN, IN CLEAN FORM

1. A composition for chemical mechanical planarization comprising an aqueous solution of ozone and abrasive particles.
2. A composition as in claim 1 wherein said abrasive particles are selected from the group consisting of alumina, silica, ceria, spinel, zirconia and mixtures thereof.
3. A composition as in claim 1 further comprising at least one additive selected from the group consisting of carbonate, bicarbonate, oxalic acid, formic acid, acetic acid, glycol acids and mixtures thereof.
4. A composition as in claim 1 wherein a concentration of ozone in said aqueous solution is less than that at which ozone interactions occur.
5. A composition as in claim 4 wherein said concentration of ozone is less than about 20 parts per million.
6. A composition as in claim 1 further comprising at least one ammonium salt.
7. A composition as in claim 6 wherein said at least one ammonium salt is ammonium carbonate.
8. A method of planarizing a surface by directing ozone gas onto said surface.
9. A method of planarizing a surface by directing onto said surface an aqueous solution containing ozone and causing relative motion of said surface and a polishing pad in contact therewith.
10. A method as in claim 9 further comprising abrasive particles in said aqueous solution.

11. A method as in claim 10 wherein said abrasive particles are selected from the group consisting of alumina, silica, ceria, spinel, zirconia and mixtures thereof.

12. A method as in claim 10 further comprising at least one ammonium salt in said aqueous solution.

13. A method as in claim 12 wherein said at least one ammonium salt is ammonium carbonate.

LAW OFFICES OF
SKJERVEN MORRILL
MAY PHERSON LLP
THREE EMBARCADERO CENTER
28TH FLOOR
SAN FRANCISCO, CA 94111
(415) 217-6000
FAX (415) 434-9646